

Attorney Docket No. 262/014

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re patent application of

Byung-Hee KIM, et al.

Serial No. 10/035,257

Filed: January 4, 2002

For: METHOD OF FABRICATING METAL LINES IN A SEMICONDUCTOR DEVICE

Group Art Unit: 2822

Examiner: M. Guerrero

Fee only

**INFORMATION DISCLOSURE STATEMENT
UNDER 37 C.F.R. §1.56**Commissioner for Patents
Alexandria, VA 22313-1450

Sir:

Submitted herewith on Form PTO/SB/08 (or PTO-1449, *modified*) is a listing of a document(s) known to applicant in order to comply with applicant's duty of disclosure pursuant to 37 C.F.R. §1.56.

☒ A copy of each listed document is being submitted to comply with the provisions of 37 C.F.R. §§1.97 & 1.98. [Box checked if applicable.]

☐ A copy of each listed non-U.S. patent and/or patent publication and cited literature is being submitted to comply with the provisions of 37 C.F.R. §§1.97 & 1.98. Cited U.S. patents and patent publications are *not* attached in accordance with the waiver set forth in the Notice by the Deputy Commissioner for Patent Examination Policy dated July 11, 2003, applicable to applications having a U.S. filing date *after* June 30, 2003. [Box checked if applicable.]

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